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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/528,265	03/17/2005	Hideomi Koinuma	052267	2280
	7590 10/07/200 , HATTORI, DANIEL	EXAMINER		
1250 CONNECTICUT AVENUE, NW			LUND, JEFFRIE ROBERT	
SUITE 700 WASHINGTON, DC 20036			ART UNIT	PAPER NUMBER
			1792	
			NOTIFICATION DATE	DELIVERY MODE
			10/07/2009	ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentmail@whda.com

	Application No.	Applicant(s)				
	10/528,265	KOINUMA ET AL				
Office Action Summary	Examiner	Art Unit				
	Jeffrie R. Lund	1792				
The MAILING DATE of this communication app	pears on the cover sheet with the c	orrespondence address				
Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPL' WHICHEVER IS LONGER, FROM THE MAILING D. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1)⊠ Responsive to communication(s) filed on 24 Ju	ılv 2009					
,	action is non-final.					
<i>i</i>						
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>4-13</u> is/are pending in the application.						
4a) Of the above claim(s) <u>4-7,12 and 13</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6) Claim(s) <u>8-11</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	r election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examine	er.					
10)⊠ The drawing(s) filed on <u>17 March 2005</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correct	ion is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).				
11)☐ The oath or declaration is objected to by the Ex	caminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list		ed.				
des the attached detailed office detail for a list	5. 1.0 55.154 55plo5 not 1056ive					
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da 5) Notice of Informal P					
Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	6) Other:	αιστι πρριισαιιστι				

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DETAILED ACTION

Election/Restrictions

1. Newly submitted claims 12 and 13 are directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: Claims 8-11 and claims 12 and 13 are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another and materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the apparatus as claimed can be used to practice another and materially different process such as depositing a single material with a specific cross section, or etching.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, claims 12 and 13 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Claim Rejections - 35 USC § 112

- The following is a quotation of the second paragraph of 35 U.S.C. 112:
 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claims 8-11 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. The claims include the limitation "sufficiently large". It

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is not clear how large "sufficiently large" is, thus, the claim fails to particularly point out and distinctly claim the subject matter.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 6. Claims 8-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Li, US Patent 6,911,129.

Li teaches a masking mechanism that includes a mask 58 and means for moving the mask 59 in a uniaxial direction (x) over a first material source 53A, a second material source 53B, and a third material source 53C. (Figure 4, column 5 lines 32-60) The mask includes slots 67 and a peripheral edge (edge of the mask) (Figure 6a, 6b)

Li also teaches various masks for forming various binary and ternary phase films,

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including, a mask that includes a first single action edge 85A with an angle of 90° + α for a first material; second single action edge 85B with an angle of 30° + α for a second material; and a third single action edge 85C with an angle of -30° + α for a third material arranged in an equilateral triangle (i.e. spaced 120° relative to each other). Such that said first single action edge acts to determine a film thickness gradient of a first material, said second single action edge acts to determine a film thickness gradient of a second material, said third single action edge acts to determine a film thickness gradient of a third material, and the film is a ternary phase diagrammatic system which is composed with the first, second and third materials (Figure 9, column 8 lines 13-23)

Li differs from the present invention in that Li does not teach the specific arrangement or size of action edges.

The motivation for arranging the action edges of Li in a specific pattern of a specific size is to form a specific mask for depositing a specific film having a desired distribution of materials. Furthermore it has been held that:

- a. a change in shape is a matter of choice which a person of ordinary skill in the art would have found obvious. (See *In re Dailey*, 357 F.2d 669,149 USPQ 47 (CCPA 1966) MPEP 2144.04.IV.B);
- b. It was held in *Gardner v. TEC Systems, Inc.*, 725 F.2d 1338, 220 USPQ 777 (Fed. Cir. 1984), cert. denied, 469 U.S. 830, 225 USPQ 232 (1984), by the Federal Circuit that, where the only difference between the prior art and the claims was a recitation of relative dimensions of the claimed device and a device having the claimed relative dimensions would not perform differently than the

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prior art device, the claimed device was not patentably distinct from the prior art device. (Also see MPEP 2144.04 (IV)(A)), and

c. applying a known technique to a known device ready for improvement to yield predictable results is obvious (see KSR International Co. v. Teleflex Inc.).

Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to arrange and size the action edges of Li in a specific pattern to form a specific mask to deposit a specific film have a desired distribution of materials as taught by Li.

Response to Arguments

7. Applicant's arguments filed June 23, 2009 have been fully considered but they are not persuasive.

In regard to Applicant's arguments directed to Li, the Examiner disagrees for the following reasons:

- a. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986). Applicant has attacked each embodiment individually and has pointed out missing elements in each, but has not addressed the elements taught by each embodiment or the combination of the embodiments as proposed in the rejection.
- b. In response to applicant's argument that it would not be obvious to

teaches the claimed invention.

combine the two embodiments, the test for obviousness is not whether the features of a secondary reference may be bodily incorporated into the structure of the primary reference; nor is it that the claimed invention must be expressly suggested in any one or all of the references. Rather, the test is what the combined teachings of the references would have suggested to those of ordinary

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c. The embodiment of figure 4 teaches a mask and means of moving a mask. The embodiment of figures 8 and 9 teach specific mask openings arrangement and individual material supply that result in a ternary phase diagrammatic system. Therefore, the combination of the two embodiments

skill in the art. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981).

d. The Examiner recognizes that the source (53a-c) of the embodiment of figure 4 is different than the three sources (73a-c) in the embodiment 8 and 9. However, the source 53a-c is capable of supply any single source or mixture of sources for each individual source of the ternary layer. Furthermore, no source is claimed.

Conclusion

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jeffrie R. Lund whose telephone number is (571) 272-1437. The examiner can normally be reached on Monday-Thursday (10:00 am - 9:00 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

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supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Jeffrie R. Lund/ Primary Examiner Art Unit 1792

JRL 10/1/09